

Standardized Form D

**MADRID AGREEMENT CONCERNING THE INTERNATIONAL REGISTRATION
OF MARKS AND PROTOCOL RELATING TO THAT AGREEMENT**

STATEMENT OF GRANT OF PROTECTION

Sent to the International Bureau of the World Intellectual Property Organization (WIPO) in
accordance with Rule 17(6) of the Common Regulations under the Madrid Agreement and Protocol

I. Office sending the statement:

BUSINESS AND INTELLECTUAL PROPERTY AUTHORITY (BIPA)

II. Number of the international registration:

1507102

III. Name of the holder of the international registration:

SHENZHEN YONGNUO PHOTOGRAPHIC EQUIPMENT CO., LTD.

- IV. ☐ All procedures before the Office have been completed; protection is accordingly granted to the mark that is the subject of this international registration (Rule 17(6)(i))
- ☒ The *ex officio* examination in respect of this international registration has been completed and no grounds for refusal have been found; however the protection of the mark is still subject to opposition or observations by third parties; the opposition period will start on.....and will expire on.....(Rule 17(6)(ii)) **60 DAYS FROM THE DATE OF PUBLICATION IN THE IP BULLETIN**
- ☐ The opposition period in respect of this international registration has expired without any opposition being filed; protection is accordingly granted to the mark that is the subject of the international registration (Rule 17(6)(iii))

V. Date of the statement:

04/12/2020

VI. Signature or official seal of the Office sending the statement:

